

UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE
United States Patent and Trademark Office
Address: COMMISSIONER FOR PATENTS
P.O. Box 1450
Alexandria, Virginia 22313-1450
www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/665,346	09/22/2003	Yujin Yamazaki _	826.1895	7037
21171	7590 09/10/	004	EXAMINER	
STAAS & HALSEY LLP SUITE 700			CHANG, AUDREY Y	
1201 NEW YORK AVENUE, N.W. WASHINGTON, DC 20005			ART UNIT	PAPER NUMBER
			2872	

DATE MAILED: 09/10/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
	10/665,346	YAMAZAKI ET AL.				
Office Action Summary	Examiner	Art Unit				
	Audrey Y. Chang	2872				
The MAILING DATE of this communic Period for Reply	ation appears on the cover sheet wi	ith the correspondence address				
A SHORTENED STATUTORY PERIOD FO THE MAILING DATE OF THIS COMMUNIC - Extensions of time may be available under the provisions of after SIX (6) MONTHS from the mailing date of this communication. If the period for reply specified above is less than thirty (30) If NO period for reply is specified above, the maximum statuse. Failure to reply within the set or extended period for reply with any reply received by the Office later than three months after earned patent term adjustment. See 37 CFR 1.704(b).	ATION. 37 CFR 1.136(a). In no event, however, may a rication. days, a reply within the statutory minimum of thin tory period will apply and will expire SIX (6) MON II, by statute, cause the application to become AE	reply be timely filed ty (30) days will be considered timely. ITHS from the mailing date of this communication. BANDONED (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on						
2a) This action is FINAL . 2b	action is FINAL . 2b)⊠ This action is non-final.					
	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims	, 200 . 20 . 20 . . 20					
· <u>_</u>	nlication					
	Claim(s) 1-13 is/are pending in the application.					
4a) Of the above claim(s) is/are withdrawn from consideration. 5) Claim(s) is/are allowed.						
6)⊠ Claim(s) <u>1-13</u> is/are rejected.	<u> </u>					
7) Claim(s) is/are objected to.	• • • • • • • • • • • • • • • • • • • •					
8) Claim(s) are subject to restricti	on and/or election requirement.					
Application Papers						
9)☐ The specification is objected to by the	Examiner.					
10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) including t						
Priority under 35 U.S.C. § 119	•					
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of:						
1. Certified copies of the priority documents have been received.						
	ocuments have been received in A	Application No				
•	f the priority documents have been					
application from the Internation	al Bureau (PCT Rule 17.2(a)).					
* See the attached detailed Office action	for a list of the certified copies not	received.				
Attachment(s)						
1) Notice of References Cited (PTO-892) 4) Interview Summary (PTO-413) Paper No(s)/Mail Date						
 Notice of Draftsperson's Patent Drawing Review (PT 3) Information Disclosure Statement(s) (PTO-1449 or Paper No(s)/Mail Date 9/22/03, 3/11/04. 		nformal Patent Application (PTO-152)				

Application/Control Number: 10/665,346

Art Unit: 2872

DETAILED ACTION

Claim Rejections - 35 USC § 112

- 1. The following is a quotation of the second paragraph of 35 U.S.C. 112:
 - The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.
- 2. Claims 1-13 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

The phrase "a first multi-layer film with a first refractive index" and the phrase "a second multi-layer film with a second refractive index" recited in claim 1 are completely confusing and indefinite since it is really not clear if in each of the phrases, it means there is a single film having a first (or a second) refractive index or a multi-layer film (i.e. a plural layers of film). It is really not clear if each of the films has a multi-layer structure, that is to say with more than one film, then how can it have a single refractive index. On the other hands if each film is just a single layer film, what then is the meaning of the term "multi-layer". The scopes of the claims are really unclear and indefinite.

The phrase "the distortion of the substrate that is due to the difference in stress between the first and second multi-layer films formed on the first and second films, respectively" recited in claim 1 is very confusing and indefinite since it is not clear what stress and distortion are concerned here and *where* are these stress and distortion occurs.

The phrase "almost the same" recited in claim 6 is not clear and indefinite since it is not clear to what degree the term "almost" should be considered.

The features concerning the "fixing material" recited in claims 6-13 are confusing and indefinite since the claims lack a structural relationship and *logical* relationship between the fixing material and the optical device to define an operable and definite optical system. At this juncture the limitations

Application/Control Number: 10/665,346

Art Unit: 2872

concerning the fixing material can only broadly interpreted as one can arbitrarily adhered the optical device to any other element.

Clarifications are required.

Claim Rejections - 35 USC § 103

- 3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 4. Claims 1-13 are rejected under 35 U.S.C. 103(a) as being unpatentable over the patent issued to Shirasaki (PN. 5,930,045) in view of the patent issued to Fujii (PN. 5,424,876).

Shirasaki teaches a virtual imaged phased array (VIPA) that is comprised of a substrate (164, Figures 12(A)) and a first reflecting film (166) placed on a first surface of the substrate and a second reflecting film (168) placed on a second surface of the substrate. The two reflecting films each comprises at least one layer and implicitly has a first and second refractive index. Since the term "multi-layer film" is not definitely defined here, (for the reasons stated above), it cannot be addressed here.

This reference has met all the limitations of the claims with the exception that it does not teach explicitly that the VIPA has a *stress correction film* formed on one of the reflecting films. **Fujii** in the same field of endeavor teaches to use a *silicon dioxide layer* in a *multi-layer mirror* such that the silicon dioxide layer imposes a compressive stress on the substrate of the multi-layer mirror such that the stress on the substrate resulted from all the other multi-layer films in the mirror may be reduced, (please see column 2, lines 1-49). It would then have been obvious to apply the teachings of **Fujii** to add a silicon dioxide layer to the VIPA as a stress correction layer for the benefit of reducing the possible damages or distortion to the substrate of the VIPA induced by the stress of the reflecting films and by the expansion of the substrate under high heat environment. With regard to claims 2-4, Fujii teaches that the stress

Application/Control Number: 10/665,346

Art Unit: 2872

correction film is a silicon dioxide film and its thickness may be adjusted to properly reduce the stress. The thickness of the silicon dioxide film is also selected so that it *does not effect* the optical property of the multi-layer mirror. It is a well-known knowledge in the art that in a multi-layer film structure, in order for the layer not to effect the optical property the layer should have an optical thickness of half or multiple of half of the specific wavelength of interested in order for the light effected by the layer be completely out of phase. Such modification therefore is considered obvious to one skilled in the art so that the silicon dioxide layer will not effect the reflectivity of the reflective layers (166 or 168). The optical flatness of the substrate being within one wavelength or less is rather standard in the art for the purpose of reducing unwanted scattering of the light at the surface.

With regard to claim 5, Shirasaki teaches that the VIPA (240, Figures 17-20) may be utilized with a mirror (254) to realize a dispersion compensator.

With regard to claims 6-13, the features concerning the fixing material are not well defined for the reasons stated above. The scopes of the claims therefore are not clear. The features can only be broadly interpreted as the VIPA can be arbitrarily adhered to any elements as desired. Shirasaki teaches that the VIPA can be adhered or fixed onto to a protector plate (174, Figure 12(c) and 12(D)) using a transparent adhesive (172, please see column 10 liens 18-46). The protector plate then serves as the fixing material. Although this reference does not teach that the protector plate is made of the various materials claimed, such modifications would have been obvious to one skilled in the art for selecting desired materials as the protector plate to protect the VIPA in different environments as needed and desired. The fixing to the protector plate may be considered as optically jointed.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Audrey Y. Chang whose telephone number is 571-272-2309. The examiner can normally be reached on Monday-Friday (8:00-4:30), alternative Mondays off.

Art Unit: 2872

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Drew Dunn can be reached on 571-272-2312. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Audrey Y. Chang Primary Examiner Art Unit 2872

A. Chang, Ph.D.